

PATENT APPLICATION
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80214

Tsutomu SHOKI, et al.

Appln. No.: 10/789,990

Group Art Unit: 1756

Confirmation No.: 9533

Examiner: Stephen D. Rosasco

Filed: March 2, 2004

For: REFLECTIVE MASK BLANK HAVING A PROGRAMMED DEFECT METHOD OF PRODUCING THE SAME, REFLECTIVE MASK HAVING A PROGRAMMED DEFECT AND METHOD OF PRODUCING THE SAME, AND SUBSTRATE FOR USE IN PRODUCING THE REFLECTIVE MASK BLANK OR THE REFLECTIVE MASK HAVING A PROG

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. § 1.136, Applicant hereby petitions for an extension of time of three month(s), extending the time for responding to the Office Action of September 19, 2006 to March 19, 2007.

The statutory fee of \$1020.00 is being charged to Deposit Account No. 19-4880 via EFS Payment Screen. The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

/Alan J. Kasper/

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Date: March 19, 2007